

(FILE 'HOME' ENTERED AT 13:04:40 ON 04 NOV 2004)

FILE 'INSPEC, CAPLUS' ENTERED AT 13:04:47 ON 04 NOV 2004

L1 23589 S SIGE OR SILICON GERMANIUM
L2 83053 S RECRYSTALLIZATION OR RE-CRYSTALLIZATION
L3 77 S L1 AND L2
L4 0 S L3 AND (NICKEL OR NI)
L5 14 S L3 AND STRAINED

FILE 'STNGUIDE' ENTERED AT 13:06:27 ON 04 NOV 2004

FILE 'INSPEC, CAPLUS' ENTERED AT 13:09:57 ON 04 NOV 2004

L6 35905 S SILICON OXIDE
L7 34924 S SILICON DIOXIDE
L8 68436 S L6 OR L7
L9 2485619 S (OXYGEN OR O) OR (HELIUM OR HE)
L10 22697 S L9 (S) (DOPING OR IMPLANTATION)
L11 22697 S L9 AND L10
L12 725 S L8 AND L11
L13 3346 S SMALL CRYSTALS
L14 0 S L12 AND L13
L15 71884 S VOIDS OR VOID
L16 4 S L15 AND L12

FILE 'STNGUIDE' ENTERED AT 13:12:05 ON 04 NOV 2004

FILE 'INSPEC, CAPLUS' ENTERED AT 13:14:13 ON 04 NOV 2004

L17 77 S ITOX
L18 47 S L9 AND L17
L19 5 S L18 AND L1

FILE 'STNGUIDE' ENTERED AT 13:14:55 ON 04 NOV 2004

FILE 'INSPEC, CAPLUS' ENTERED AT 13:16:25 ON 04 NOV 2004

L20 4090 S INTERNAL OXIDATION
L21 1683 S L20 AND L9
L22 3 S L20 AND L1